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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Chao-Hu Liang, Examiner: MAI, ANH D

5 Chih-Hung Chen,
Yu-Shan Tai,
Po-Lun Cheng

Filing Date: 03/25/2002 Art Unit: 2814

Serial No.: 10/063,128 Docket No.: NAUP0385USA

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Title: METHOD OF FORMING A POLYSILICON LAYER

To: Commissioner for Patents

P.O. Box 1450

15 Alexandria, VA 22313-1450

Subject: Response to the Office Action dated 04/22/2003

20 Dear Sir/Madam:

INTRODUCTORY COMMENTS

In response to the Office Action identified above,
25 the above-identified application is to be amended as indicated in the following sections. Consideration of all amendments is politely requested.

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